



Synchronous Defect and Interface Engineering of NiMoO₄ Nanowire Arrays for High-Performance Supercapacitors

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EXPERIMENTAL SECTION

Preparation of NiMoO₄ nanowire arrays (NWAs)

All the reagents were analytical grade and used without further purification. The nickel sulfate (NiSO₄·6H₂O) and sodium molybdate (Na₂MoO₄·2H₂O) were obtained from Aladdin reagent (Shanghai) Corporation. The ferronickel foam substrate (5 × 2 cm²) was immersed in 10wt.% hydrochloric acid solution to remove the surface oxide layer, followed by rinsing with distilled H₂O and drying at 60 °C for 1 h. 1.5 mmol of NiSO₄·6H₂O and 1.5 mmol of Na₂MoO₄·2H₂O were dissolved in 50 mL of distilled water under constant magnetic stirring for 10 min. Then, the resulting mixed solution was transferred into 100 mL Teflon-lined stainless-steel autoclave with pretreated ferronickel foam substrate inside. The autoclave was maintained at 150 °C for 6 h. After the hydrothermal reaction, the NiMoO₄ nanowire arrays (NWAs) precursor was cleaned by ultrasonic treatment in deionized water for 5 min to remove any loosely attached nanoparticles adsorbed on the surface. Finally, the NiMoO₄ NWAs precursor was annealed at 350 °C for 2 h in Ar with a heating rate of 10 °C min⁻¹. The average mass loading of NiMoO₄ NWAs was determined to be *ca.* 1.3 mg cm⁻².

Preparation of NiMoO_{4-x}@C composite

NiMoO_{4-x}@C composite was prepared by coating amorphous carbon shell on the surface of NiMoO₄ NWAs via thermal decomposition reaction of sucrose. In a typical procedure, the as-prepared NiMoO₄ NWAs (1.3 mg cm⁻² × 10 cm² = 13 mg) were firstly immersed in 50 mL of 0.1 mol L⁻¹ sucrose solution for 6 h, followed by drying at 60 °C in vacuum for 1 h. Then, the sucrose-coated NiMoO₄ NWAs were annealed at 400 °C for 2 h in Ar, followed by cooling to room temperature naturally to obtain the final NiMoO_{4-x}@C product. To study the effects of annealing temperature on the structure and electrochemical properties, the sucrose-coated NiMoO₄ NWAs were also calcined at 200 °C, 600 °C, and 800 °C, respectively, for comparison.

Characterizations

Scanning electron microscopy (SEM, Quanta250 FEG, 30 kV), transmission electron microscopy (TEM, JEM-2100, 200 kV), X-ray diffractometer (XRD, domestic DX-2700, Cu K α radiation: $\lambda = 1.5406 \text{ \AA}$), X-ray photoelectron spectrometer (XPS, K-Alpha+), and Raman spectroscopy (LabRAM HR Evolution in HORIBA) were used to characterize the as-received samples. Cyclic voltammetry (CV), galvanostatic charge and discharge (GCD) and electrochemical impedance spectroscopy (EIS, frequency range of 100 kHz to 0.1 Hz) were tested by CHI660E electrochemical workstation at room temperature.

Electrochemical measurements

The electrochemical performance of NiMoO₄ NWAs and NiMoO_{4-x}@C were tested by using three-electrode system in a 2 M KOH aqueous solution. Hg/HgO electrode was used as reference electrode, platinum plate was used as counter electrode and NiMoO_{4-x}@C composite (or NiMoO₄ NWAs) electrode with a size of 1 × 1 cm² was used as the working electrode. For the two-electrode system, an asymmetric supercapacitor device (NiMoO_{4-x}@C//AC) was assembled with the NiMoO_{4-x}@C as positive electrode and activated carbon (AC) as negative electrode, respectively, 2 M KOH as the electrolyte and cellulose paper as the separator. According to the principle of charge balance following the relationship $q^+ = q^-$. The charge stored by each electrode depends on the specific capacitance (C), the potential range for the charge/discharge process (ΔE) and the mass of the electrode (m) following the equation:

$$q = C \times \Delta E \times m$$

and in order to get $q^+ = q^-$, the mass balancing follows the equation:

$$\frac{m^+}{m^-} = \frac{C_- \times \Delta E_-}{C_+ \times \Delta E_+}$$

the mass ratio of positive and negative electrodes is about 1:4.08. Based on the mass of NiMoO_{4-x}@C (1.3 mg), 5.3 mg of activated carbon was used to assemble the device, and thus the total mass of NiMoO₄/AC//ACNE is 6.6 mg. The areal capacitance was calculated from the discharge curve as follows: $C = It / (\Delta V * S)$, where C (F cm⁻²) is the areal capacitance, I (A) is the discharge current, t (s) is the discharge time, ΔV (V) is the potential window, and S (cm²) is the area of NiMoO₄/AC electrode. All the electrochemical tests were carried out at room temperature.

Computational details

Spin-polarized first-principles density functional theory (DFT) calculations were performed using projector augmented wave (PAW) pseudopotentials with an exchange-correlation functional of Perdew-Burke-Ernzerhof (PBE) formation as implemented in VASP [1,2]. An energy cutoff of 520 and 400 eV was adopted for NiMoO₄ conventional cell (containing 8 Ni atoms, 8 Mo atoms and 32 O atoms) and surface slabs, respectively. The k -point sampling was obtained using a Γ -centered Monkhorst-Pack scheme with a 3 × 3 × 4 mesh for conventional cell and 2 × 2 × 1 mesh for surface slabs, respectively. The convergence criteria for SCG iteration and force were set to 1.0 × 10⁻⁵ eV/atom and 0.015 eV/Å for NiMoO₄ conventional cells while 1.0 × 10⁻⁴ eV/atom and 0.05 eV/Å for surface slabs, respectively. The NiMoO₄ (110) surface slab consists of five atomic layers with 24 Ni atoms, 24 Mo atoms and 96 atoms, with a size 15.52 Å × 12.50 Å × 23.41 Å which includes 15 Å vacuum layer along z-axis to avoid unwanted interactions among neighboring layers. To simulate the defective NiMoO₄ (110) surface, one surface O atom was removed from the surface slab. PBE+ U method with $U = 6.2$ and 4.38 eV was added to the 3d orbitals of Ni and Mo, respectively to adjust the strength of Coulomb and exchange interactions.

The adsorption energies (E_{ads}) were determined using the following equation:

$$E_{\text{ads}} = E_{\text{mol/sub}} - (E_{\text{mol}} + E_{\text{sub}})$$

where $E_{\text{mol/sub}}$, E_{mol} and E_{sub} denote the total electronic energies of NiMoO_4 surface with adsorbed OH, OH molecule in gas phase, and clean NiMoO_4 surface, respectively. During the surface calculations, dipole correction was adopted along z-axis and van der Waals interactions were considered using DFT-D method. The drawing of the calculated data was performed using VESTA [3]. Some pre- and post-treatment processes were carried out with the assistance of VASPKIT [4].

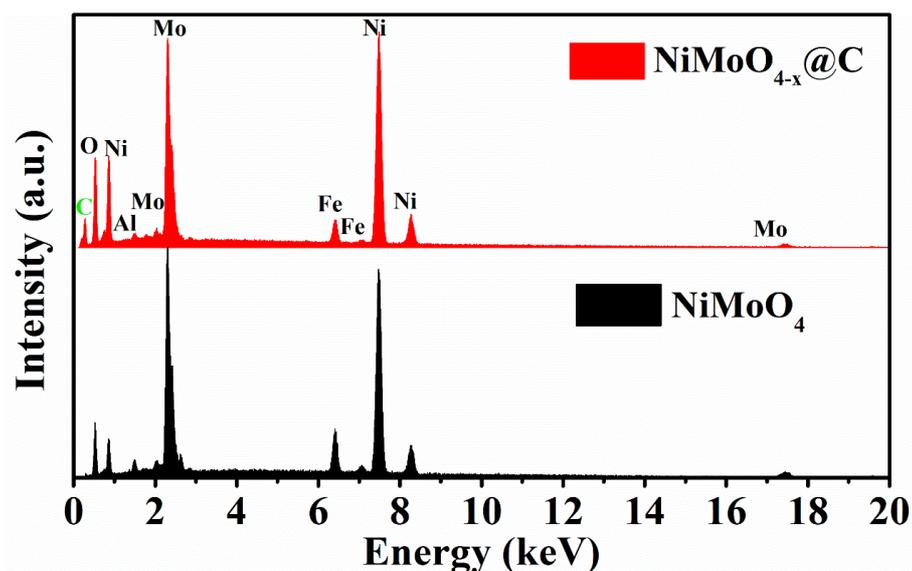


Figure S1. The EDS analysis of $\text{NiMoO}_{4-x}@\text{C}$ composite and NiMoO_4 NWAs.

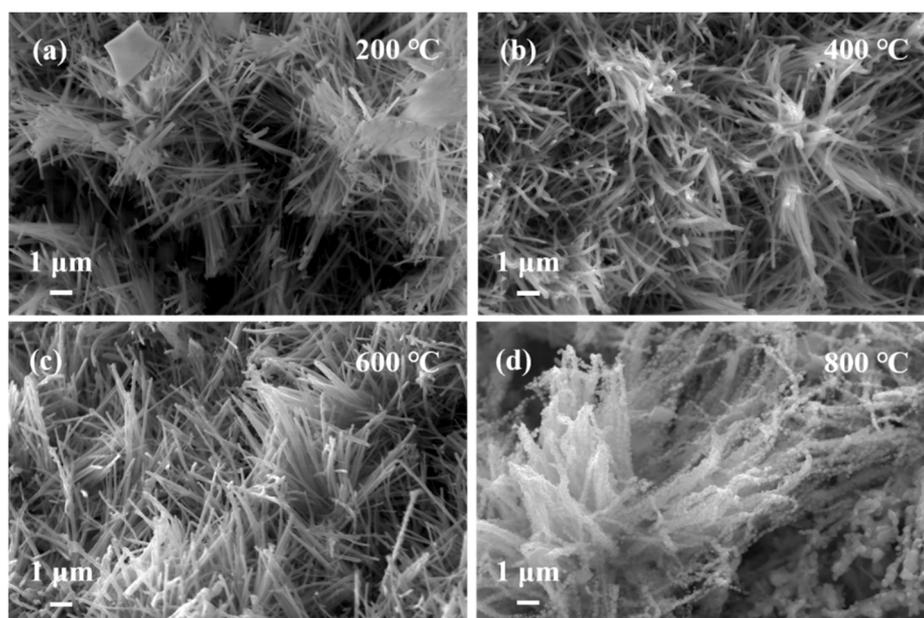


Figure S2. SEM images of the $\text{NiMoO}_{4-x}@\text{C}$ composite prepared under different annealing temperature: (a) 200 °C, (b) 400 °C, (c) 600 °C and (d) 800 °C.

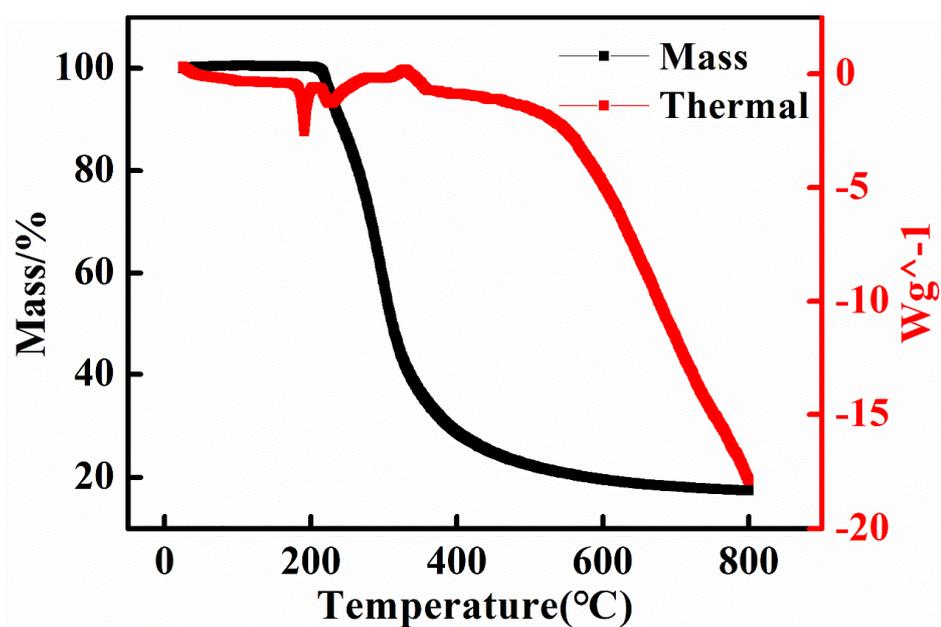


Figure S3. Thermogravimetric (TG) and differential scanning calorimetry (DSC) analysis of sucrose in Ar atmosphere at a ramping rate of $10\text{ }^{\circ}\text{C min}^{-1}$.

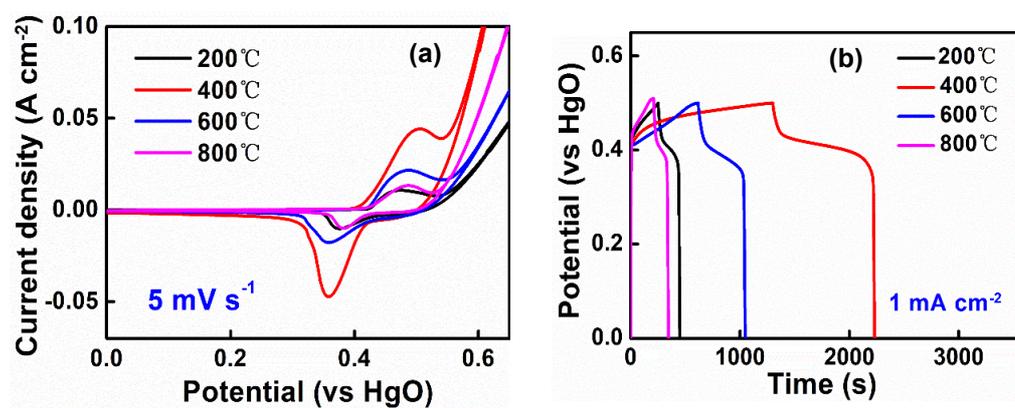


Figure S4. (a) CV and (b) GCD of $\text{NiMoO}_{4-x}\text{@C}$ samples prepared under different annealing temperatures.

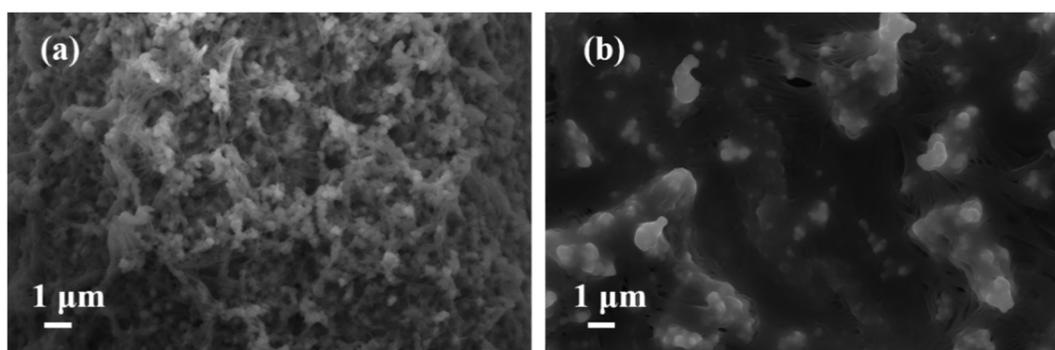


Figure S5. SEM images of the (a) $\text{NiMoO}_{4-x}\text{@C}$ and (b) NiMoO_4 NWAs electrodes after 10,000 cycles at 20 mA cm^{-2} .

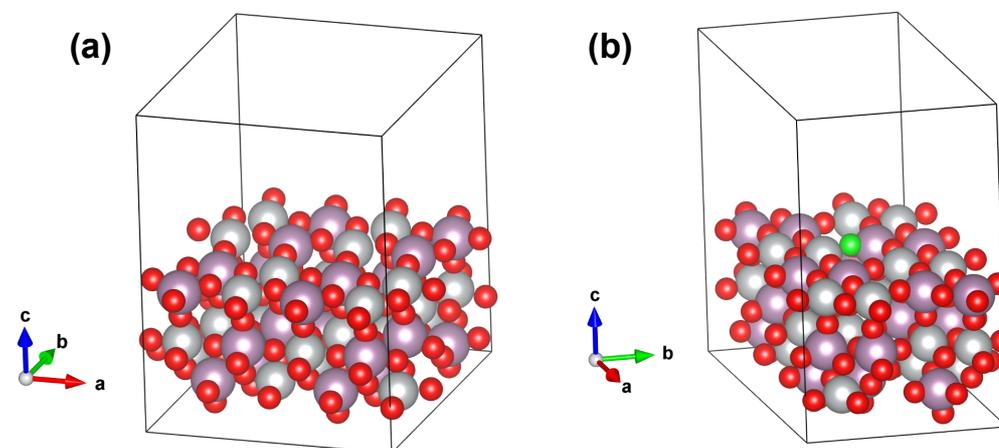


Figure S6. Optimized geometry structures of the (a) pristine NiMoO₄ (110) surface and (b) oxygen-deficient NiMoO₄ (110) surface obtained by removing one surface O atom (green). The grey, light pink and red balls represent the Ni, Mo and O atoms, respectively.

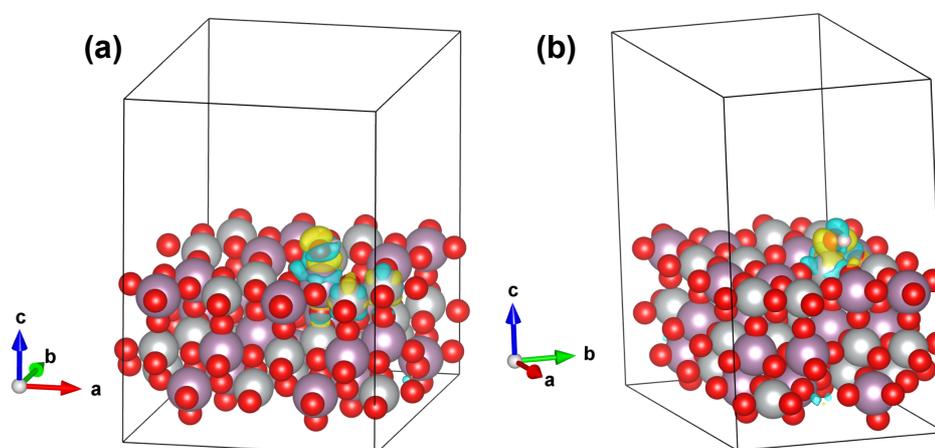


Figure S7. Charge density difference contours of after adsorption of one HO molecule on (a) Mo- and (b) Ni-side of NiMoO₄ (110) surface, respectively. The yellow and cyan colors denote the electron gain and loss, respectively. The isosurface level is 0.001 e bohr⁻³.

Table S1. Brief comparison of electrochemical performance of current work with recently relevant literature.

Electrode materials	Specific capacity ($F g^{-1}$)	Cycling stability (Cycles)	Ref.
NiMoO₄/AC	1720 $F g^{-1}$ at 0.8 $A g^{-1}$	84.5% (6000)	This work
groove-like NiMoO ₄ hollow nanorods	1102.2 $F g^{-1}$ at 1 $A g^{-1}$	90% (1000)	[5]
Co ₃ O ₄ @NiMoO ₄	1476 $F g^{-1}$ at 1 $A g^{-1}$	96% (2000)	[6]
NiMoO ₄ /CoMoO ₄	1445 $F g^{-1}$ at 1 $A g^{-1}$	78.8% (3000)	[7]
CNTs/C/NiMoO ₄	1037 $F g^{-1}$ at 1 $A g^{-1}$	NA	[8]
CNF/NiMoO ₄	1675 $F g^{-1}$ at 1 $A g^{-1}$	83.6% (3000)	[9]
NMO@CC	970 $F g^{-1}$ at 2.5 $A g^{-1}$	91.34% (5000)	[10]
NG/NiMoO ₄	62.5 $F g^{-1}$ at 0.5 $A g^{-1}$	94.2% (5000)	[11]
NiMoO ₄ /rGO	1400 $F g^{-1}$ at 1 $A g^{-1}$	91% (2000)	[12]
Ni _{0.85} Co _{0.15} MoO ₄	1301 $F g^{-1}$ at 1 $A g^{-1}$	86% (3000)	[13]
NiMoO ₄ @Ni ₉ S ₈ /MoS ₂	488.9 $F g^{-1}$ at 1 $A g^{-1}$	81.0% (10000)	[14]
rGO/NiMoO ₄	680 $F g^{-1}$ at 3 $A g^{-1}$	68% (4000)	[15]
NMO-NS	1221.2 $F g^{-1}$ at 1 $A g^{-1}$	89.2% (10000)	[16]
NiO@NiMoO ₄ @PPy	1645.1 $F g^{-1}$ at 1 $A g^{-1}$	77.1% (30000)	[17]

NA: not available.

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